# SUMMARY

in master's programme Biomedical Engineering Course 362.118 Biomedical Microsystems

# Summary of the course

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### 1 Fabrication of Micro- and Nanostructures



#### **1.1 Furnace Process**

Thermal oxidation:

- Dry oxidation: Si + O<sub>2</sub>  $\rightarrow$  SiO<sub>2</sub>
- Wet oxidation: Si + 2 H<sub>2</sub>O  $\rightarrow$  SiO<sub>2</sub> + 2 H<sub>2</sub>

#### 1.2 Thin film growth = Deposition

A single atom appearers, then a second one, they attached to each other. More atoms go to this and it grows by attaching together.

	Physical	Chemical
Dry (= vacuum )	Physical vapor deposi- ton (PVD), Molecular Beam Epitaxy (MBE), Sputter depo- sition	Chemical vapor deposi- tion (CVD), Atomic layer depositon (ALD)
Wet (= liquid)	Spin coating	Electro plating, Electro less plating

PVD process is done by melting metal and steam it on the surface.

Sputter deposition use a High-frequency plasma.

Spin coating have we done in the laboratory exercise.

CVD Chemical reactive gases are used to synthesize thin solid films. Can be classified by

the operating pressure (atmospheric pressure, low-pressure, ultra-high vacuum).

ALD Two gases are sequentially supplied.

Electron plating/Less plating is a RedOX reaction. Non-galvanic type of plating. Use of electrical current to reduce cation of a desired material form a solution and coat a conductive object with a thin layer of the material.

#### 1.3 Pattering

Lift-off	Etch-bak	
1) Pattern Photoresist	1) Material deposition	
2) Material deposition	2) Pattern Photoresist	
3) Lift of (= Striping)	3) Etching	
	4) Striping of Photoresist with a ionic solvent	

Define a pattern  $\rightarrow$  Lithography Transfer the pattern  $\rightarrow$  Etching

Positive lithography is when this part, who stays during exposure in the shadow, get insoluble.



Below of 157 nm light is absorbed by all materials. UV-light changes Diazonaphtochion in Carboxyl acid.



#### 1.4 Etching

Methods of Etching:

- Wet etching  $\rightarrow$  Isotropic
- Plasma etching
- Ion beam etching/Ion milling

### 2 Principles of Microelectronic Devices

Elements of a network:

- Independent sources
- Resistors
- Capacitors
- Switches

Superposition-theorem: Each single source contributes to the overall response independently form each other source. Superposition works for voltage and currents but not for power.  $\rightarrow$  Überlagerungsverfahren nach Helmholz Spannungsquelle wird zu einem Kurzschluss

Stromquelle zu einer Unterbrechung

Microelectronic arrays (MEA) can be used for stimulation of cells and electrophysiologic recordings.

Metal-oxide-semiconductor field-effect transistor (MOSFET) are used to amplify or switch electronic signals.



Bonding of a chip:



pMOSFET have a source and drain part which is a  $p^+$  region. The body is a n-region, as result an pnp-MOSFET. If a voltage (+) is applied by the gate the electrons (e<sup>-</sup>) of the body are went to the gate. A brig between the source and drain appears where the e<sup>-</sup> can travel from the source to the drain.

### 3 Metal-Liquid-Interfaces: inorganic and organic electrolytes

Biomedical micro devices often define a new interface between:

· metallic phase, charge carriers are electrons

· conductive solution/electrolyte, charge carriers are ions

Electrochemistry is the study of reactions in which charged particles cross the interface between two phases of matter.

Interfacial potentials can exist between any two phases in contact, even in the absence of chemical reactions. They are the result of absorption or ordered aligment of ions or molecules on the surface of a second phase.

For measuring a potential difference two contact leads of a voltmeter must be bring in contact with the object.

Water is capable to undergo oxidation and reduction. Pure water is an isolator.

Electromotive/activity series  $\rightarrow$  Similar comparison of metals mad it possible to arrange them in the order of their increasing electron-donating power.

Active metals are all "attached" by acids.

Challenges for Biomedical Micro devices:

- Charge particles may accumulate at the electrode surface
- Charged particles in the electrolyte may transfer electrons form or to the electrode surface

Voltammetry is a category of electroanalytical methods. Information about an analyte is obtained bay measuring the current as the potential is varied.



### 4 Micro- and Nanostructured Interfaces & Microfluidics



In Silico studies are biological experiments carried out entirely in a computer or via simulations. In vitro assays take place in a controlled environment, outside a living organism.

	In-vivo	In-vitro
Advantage	Complex interactions can be studied, well defined test ani- mals, cells in natural environ- ment	Reduce use of animals, ease of cultur handling, cheap, less ethical problems
Disadvantages	ethic problems, high effort, costs	some questions need a com- plex test system, behaviour studies need living animals

Primary cultures = cells cultured directly

Immortalired cell line = cells proliferate indefinitely

Immortal cells maintain telomere length with the aid of an enzyme telomerase.

### 2D vs 3D cell cultures as in-vitro models



Liquid in which cells are grown contains factors like:

- · physiologic, ph
- supraphysiologic, hormones
- · nonphysiologic, antibiotics

#### Cell types:

- · active; neuronal, heart
- passive; skin

Materials of the microchip which is interfacing with living cells have to be:

- · aviable with microelectronic fabrication
- Non-corrosive
- · Biocompatible



Patterning of surface effects cell adhesion. The different types of cell junctions:

- Tight junctions, plasma membrane
- Adherens, actin filaments
- · Desmosomes, intermediate filament
- · Hemidesmosomes, intermediate filament to basal lamina
- Gyp junctions, tunnels between cells

 $Reynoldsnumber = \frac{Interial flow}{Viscous forces} \text{ low Re = laminar flow}$ intermediate Re = transitional flow high Re = turbulent flow

2 structuring approaches of DNA chips:

- Lithographic patterning of surface (Affymetrix)
- · Drop dispersion with a micronozzle (egInkJet)



The so produces wafer is flooded with a solution that contains DNA. If the strands are complementary they fits together. The fluorescence target, that was attached to the sample, starts than to glow.



Acid's (Adenin, Guanin, Thymin, Cytosin) are printing to a tower whit this technics. They use light of different wavelengths to look if the DNA have fit.

### 5 Cell-Monitoring and Sensing: electrically inactive cells

Communication:

- Nerve cells  $\rightarrow$  ions flows through their membranes
- Electronic  $\rightarrow$  electrons flows through solid metals; faster flow between silicon and metal

ISSUE: Active microelectronic in a wet environment!

Excitable cells	Non-excitable cells
generate action potential	no own electrical signal; external signal applying
cardiac cells	endothelial cells
drive or control electrical components	changes due to metabolic processes ban be detect by electrical co



Living cells only survive in cell medium. Which is a solution with many ionic components. The measurements are performed in a electrolyte.

Basic setup of an electrochemical cell consist of:

- · electron conductor
- · ion conductor



The charge transfer takes place on both plates and acts as a capacitor.

Electrical inactive cells  $\rightarrow$  Bioimpedance Optimum setup for electrochemical cells:

- AC current
- < 2 V
- · electrodes with rough surface

Optimum setup for biochemical samples:

- · AC current
- $< 50 \, mV$
- · inert electrodes

Interdigitated electrodes are ideal for research and development. It can use for wet chemical applications. It makes gas detections possible. It is cheap, ultra clean and extremely efficient.



Transepithelial Electrical Resistance (TEER) is used to measure the confluence of cell layers.

Non-excitable cells have a permittivity, which can be measured via impedance. Biompedance allows to measure the presence, amount and junction of cells!

### 6 Cell-Monitoring and sensing: electrically active cells



The membrane potential is calculated from total ion permeability of the membrane for all ions using the Goldman equation.  $U = \frac{R \cdot T}{E} \ln \left( \frac{p_x[y]^e + \dots}{e^{-\lfloor x \rfloor_{x \to x}}} \right)$ 

Č	ing the	$F = \prod_{x \in \mathcal{F}} F = \prod_{x \in \mathcal{F}} p_x[$	$[y]^i + \dots$
	U	Voltage	[V]
	R	universal gasconstant	[J/mol]
	T	Temperature	[K]
	F	Faradey constant	[C/mol]
	p	Permeability	[]
	[X]	Concentration of different lons in/out	[]
	_	of the cell	



Na-channels open first, later follows the K-channels.

Sodium-potassium-pump maintains the Na-K-concentration gradient. It is working independent form voltage or neurotransmitter activation but it need energy like Adenosintriphosphat (ATP).

Ion selective-FET can use for DNA sequencing.



Chemical-FET, the gate is covered with a chemical selective layer that is electro-active. Drain current = f (Concentration)

In principle, a direct coupling of ionic signals in a neuron and electronic signals in the semiconductor can be attained by electrical polarization If the insulating lipid layer of the neuron is in direct contact to the insulating silicon dioxide of the chip, a compact dielectric is formed.

When nerve cells grows on a chip it does not form a compact dielectric. The cell adhesion is mediated (hält aufrecht) by protein molecules. Proteins keep the liquid membrane at a certain distance  $\rightarrow$  cleft between cell an chip.



#### **List of Abbreviations**

- ALD Atomic layer depositon
- ATP Adenosintriphosphat
- **CVD** Chemical vapor deposition
- MBE Molecular Beam Epitaxy
- MEA Microelectronic arrays
- MOSFET Metal-oxide-semiconductor field-effect transistor
- PD Physical deposition
- **PECVD** Plasma enhanced Chemical vapor depositon
- **PVD** Physical vapor depositon
- TEER Transepithelial Electrical Resistance